Level degeneracy and temperature-dependent carrier distributions in self-organized quantum dots

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Using femtosecond three-pulse pump–probe spectroscopy, we investigated the transparency condition for the ground and first excited states in self-organized In$_{0.4}$Ga$_{0.6}$As quantum dots at different temperatures and wavelengths. The temperature-dependent behavior of the transparency condition is consistent with calculations using a multilevel model with a large density of states in the quantum-well reservoir. The twofold spatial degeneracy of the first excited state and the temperature dependence of the thermal equilibrium processes were experimentally observed.

Self-organized quantum-dot (QD) active regions are being researched intensively for laser and amplifier devices because of their low threshold current density, reduced temperature sensitivity, and high differential gain. Because the temperature dependence of the optical gain results in reduced QD laser performance and efficiency at higher temperatures, the threshold currents in QD laser devices have been investigated to understand the thermal behavior of QD lasers. Although the models of quantum dots developed so far indicate a few confined discrete states in the dot and a continuum in the barrier region, real self-organized quantum dots are highly disordered with a complex electronic structure. It is, therefore, highly desirable to determine as completely as possible the actual level degeneracies of the confined states, and the effective densities of states (DOS) of the excited states, in the real self-organized QD system, since these are critical parameters which determine device performance. In this letter, we describe a method using femtosecond transient gain spectroscopy which provides accurate measurements of the transparency carrier density, and hence, the level degeneracies and DOS. The behavior of the temperature- and wavelength-dependent transparency condition measurements supports a multilevel model with a large density of states in the wetting layer, and confirms the theoretically predicted spatial degeneracy factor of 2 for the first excited state.

The In$_{0.4}$Ga$_{0.6}$As QD sample used in this work is an undoped heterostructure with four layers of In$_{0.4}$Ga$_{0.6}$As quantum dots, separated by 2.5 nm GaAs barriers, grown by molecular beam epitaxy. These layers are sandwiched between two 0.1-μm-thick GaAs layers and two outer 0.5 μm Al$_{0.3}$Ga$_{0.7}$As carrier confinement layers. The structures are grown on (001) semi-insulating GaAs substrates, which are subsequently removed through selective etching to enable differential transmission (DT) measurements. The In$_{0.4}$Ga$_{0.6}$As dots are grown at 520 °C while the rest of the sample is grown at 620 °C. Cross-sectional transmission electron microscopy shows that the dots are pyramidal in shape with a base dimension of 14 nm and a height of 7 nm. Atomic-force microscopy scans reveal a dot density of 5 × 10$^{10}$ cm$^{-2}$ per layer.

Band-structure calculations of individual QDs based on an eight-band $k \cdot p$ formalism predict several confined electronic levels and hole levels. The interband transition probabilities are high only for those transitions between electron and hole levels of the same quantum number. In real QD ensembles, these discrete levels are inhomogeneously broadened due to the size fluctuation of the dots. The first excited level in each dot has a twofold degeneracy due to the symmetry of the dot geometry, in addition to the double spin degeneracy. At low temperature, the excited state interband transition/E2H2/ is centered around 930 nm, and the ground state transition/E1H1/ is centered at 970 nm. Figure 1(a) shows DT/T spectra (i.e., DT spectra normalized to the transmitted probe spectrum) of the sample measured using a 100 fs white-light probe pulse following excitation by an optical (800 nm) pump pulse for different pump fluences; saturation of the carrier population in the ground state is clearly observed.

Femtosecond three-pulse white-light pump and probe DT spectroscopy is performed using an 85 fs, 3.5 μJ, 250 kHz Ti:sapphire regenerative amplifier system. Carriers are injected by optically pumping the GaAs barrier region (800 nm, “gain pulse”) to establish a population inversion in QDs; the intensity of the gain pulse is adjusted so that the dots can be in the absorption or gain regime. Tunable pump and probe pulses are generated by spectrally filtering two single-filament white-light sources; a 10 nm bandwidth “pump pulse” is tuned to resonantly deplete (or generate) electron–hole pairs in the ground state or the first excited state by stimulated emission (or absorption) in the gain (or absorption) regime, after a 20 ps delay with respect to the gain pulse. The depletion (generation) of carriers by the pump pulse in ground state or the first excited state gives rise
to a negative (positive) DT signal; this sign flip of the DT signal is the critical indication of gain in the QDs, and the transparency condition can be observed as zero DT signal. The pump pulse is fixed at a 20 ps time delay with respect to the gain pulse, because the carrier populations in the ground state and the excited state are saturated at this time. The pump pulse is mechanically chopped at 6 kHz, and the DT signal is measured using a lock-in amplifier; the probe DT is plotted as a function of delay following the pump pulse. The probe DT is mechanically chopped at 6 kHz, and the DT signal is measured using a lock-in amplifier; the probe DT is plotted as a function of delay following the pump pulse. The three pulses are focused on the QD sample near normal incidence; in this geometry we obtain the intrinsic single-pass transparency condition in QDs, uncomplicated by any propagation effects or device parasitics that one might have in a p-i-n waveguide structure.\(^4\)\(^-\)\(^6\)

Figure 1(b) shows time-resolved degenerate pump-probe scans of the ground state (\(E1H1\)) DT signal for different gain-pulse fluence densities at 10 K. The DT signal is positive (induced transmission) when the gain pulse fluence is zero, and becomes negative when the gain pulse exceeds the transparency fluence of 0.36 \(\mu J/cm^2\) (\(\sim 1.1 e-h\) pair per dot); this number is consistent with the data of Fig. 1(a), which shows that half of the \(n=1\) states are full at this excitation density. The numbers of \(e-h\) pairs per dot in parentheses in Fig. 1 are obtained from the measured spot size and power of the gain pulse using published values of the absorption coefficient (\(\alpha \sim 12\) 045 cm\(^{-1}\)) and reflectivity (\(R \sim 0.3285\)).\(^1\)\(^1\)

We measured the transparency condition for the ground and first excited states over the temperature range from 10 to 300 K; the experimental carrier numbers per dot for zero gain are shown in Fig. 2(a). The transparency density is one electron–hole pair per dot in the ground state at low temperature (since there is a double spin degeneracy); the transparency density of the first excited state is observed to be 4, which is exactly as expected for a spatial degeneracy of 1 in the ground state and 2 in the excited state. The transparency density exhibits a dramatic change around 100 K, which indicates that at temperatures \(>100\) K thermal excitation to higher excited states and the continuum becomes dominant.

The temperature-dependent carrier dynamics at low carrier density also show similar behavior, and we developed a Monte Carlo simulation method which can explain our experimental data.\(^1\(^2\) (Note that these zero-gain measurements are averages over the pump’s 10 nm bandwidth; thus, the reduction of threshold current within the 77–150 K range observed in threshold measurements of lasers\(^5\)\(^-\)\(^6\) is not seen in our experiments.)

The dotted lines in Fig. 2(a) are theoretical calculations using a model of discrete levels in the QD and subbands in the quantum-well (QW) reservoir. Using a standard QW calculation of 0.2 \(\mu\)m GaAs layer between two outer 0.5 \(\mu\)m Al\(_{0.3}\)Ga\(_{0.7}\)As layers, the energy levels and densities of states of the QW reservoir were obtained. The numbers of subbands in the QW are 41, 84, and 36 for electrons, heavy holes, and light holes, respectively, and these QW reservoir states contribute to QD electron and hole distribution as following for the dot density of \(n_{QD}\) with four layers:

\[
N_e = \sum_{i=1}^{3} \frac{g_i}{\exp[(E_{i,c} - \mu_e)/k_BT] + 1} + \sum_{i=1}^{4} \frac{m_e^* k_B T}{4 \pi \hbar^2 n_{QD}} \ln[1 + \exp((\mu_e - \mu_{i,c})/k_B T)],
\]
region from 960 to 980 nm at 9 K, but do change at RT. As the carrier capture probabilities from the barrier region are approximately the same for different-sized dots, the zero-gain densities are the same over the inhomogeneously broadened ground state, indicating there is no thermal equilibration process through the wetting layers or barrier at low temperature (9 K).14,15 The increase of transparency carrier numbers at the wavelength shorter than 950 nm is due to the increase of the distribution overlap with the first excited state. At temperatures above 100 K up to RT, the transparency densities increase dramatically due to thermal excitation. The variation in transparency density from 960 to 980 nm indicates thermal equilibrium at RT between different QDs (driven by thermal reemission into the barrier region and subsequent recapture).

In conclusion, we have measured the transparency condition for the ground and first excited states of undoped InGaAs QDs at different temperatures and wavelengths using a three-pulse pump–probe experiment. The spatial degeneracy factor 2 of the first excited state as well as the effect of temperature on the thermal equilibration processes is experimentally observed. The temperature-dependent behavior of transparency condition is consistent with our model calculation with a large density of states in the wetting layer and barrier region; this indicates that tunneling injection is a promising approach to avoid this limitation.13

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\[ N_e = \sum_{i=1}^{3} \frac{g_i}{\exp((\mu - E_{i,h})/k_B T)} + \frac{m_e^* k_B T}{4 \pi \hbar^2 \tilde{n}_{QD}} \times \ln(1 + \exp((E_{i,h} - \mu)/k_B T)) \times \ln(1 + \exp((E_{i,h} - E_{i,e})/k_B T)) \]

\[ N_h = \sum_{i=1}^{3} \frac{g_i}{\exp((\mu - E_{i,h})/k_B T)} + \frac{m_e^* k_B T}{4 \pi \hbar^2 \tilde{n}_{QD}} \]

\[ N_e \text{ and } N_h \text{ (} \mu_e \text{ and } \mu_h \text{) are the numbers (quasi-Fermi levels) of electrons and holes per dot, and } g_i \text{ is the state degeneracy including spin. From the zero-gain condition, we have } \mu_h = \mu_e - E_e + E_h \text{. If we choose the energy levels of the electrons and holes (} E_{i,e} \text{ and } E_{i,h} \text{), } N_e \text{ and } N_h \text{ can be obtained with the constraint } N_e = N_h \text{ by varying } \mu_e \text{ and } \mu_h \text{ (= } \mu_e - E_e + E_h \text{ from zero gain condition). We searched } E_{i,e} \text{ and } E_{i,h} \text{ for the best fit to the data, and found a model with three discrete energy levels inside QD with optical transitions at 973, 927, and 899 nm, and the wetting layers above 881 nm; these are consistent with the peaks of DT/TT spectra in Fig. 1(a). The results of the fit are shown as the dotted lines in Fig. 2(a). In this and previous experiments we have shown that the dynamics12 and parameters such as the transparency condition in real self-organized quantum dot structures are driven in large part by the presence of a large density of states in the wetting layer and barrier region in the disordered system. This will have a major effect on any quantum-dot-based optoelectronic devices (interband or intersubband laser, mid-IR detector, etc.). One promising approach to reduce this problem is to use tunneling injection device which is injecting carriers into the quantum dot active region via phonon-assisted tunneling from the two-dimensional (2D) QW directly into the zero-dimensional (0D) QD ground state.13

We also measured the wavelength-dependent transparency conditions of QDs in the spectral region from the ground state to first excited state at 9 K and room temperature (RT) as shown in Fig. 3. The transparency carrier densities around the ground state do not change in the spectral